

JPW

PATENT



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Toshiyuki Ogata et al.

Art Unit: 1712

Application No.: 10/748,190

Examiner: Marc S. Zimmer

Filed: December 31, 2003

Docket: 1608-3 DIV

Confirmation No.: 5536

For: POSITIVE RESIST COMPOSITION
AND BASE MATERIAL CARRYING
LAYER OF THE POSITIVE RESIST
COMPOSITION

Dated: October 11, 2006

I hereby certify this correspondence is being deposited with
United States Postal Service as first class mail, postpaid in
an envelope, addressed to: Commissioner for
Patents, P.O. Box 1450, Alexandria, VA 22313-1450

Date: October 11, 2006

Signature Marcy H. Mancuso *Marcy H. Mancuso*

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT AND RESPONSE PURSUANT TO 37 C.F.R. §1.111

Sir:

This is in response to the Non-final Office Action mailed July 11, 2006, a reply to which
is due by October 11, 2006, please amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this
paper.

Remarks begin on page 3 of this paper.